

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1509	51/308.ccls.	US-PGPUB; USPAT	ADJ	ON	2008/04/28 14:12
L2	59	51/308.ccls. and (silica same colloid)	US-PGPUB; USPAT	ADJ	ON	2008/04/28 14:22
L3	26	51/308.ccls. and (silica same colloid) and (alkali metal salt or ammonium salt or KCL or "KNO. sub.3" or NaCL or "K.sub.2" "so. sub.4")	US-PGPUB; USPAT	ADJ	ON	2008/04/28 14:23
L4	10	("4057939"   "4169337"   "5391258"   "5709588"   "5783489"   "5866031"   "5922091"   "6027669").PN. OR ("6300249"). URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2008/04/28 14:37
L5	18	("3715842"   "5128281"   "5228886"   "5264010"   "5693239"   "5733819"   "5891205"   "5997620"   "6027669"   "6099604"   "6174454"   "6190237").PN. OR ("6312487"). URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2008/04/28 14:49
L6	1	"4462188".pn.	US-PGPUB; USPAT	ADJ	ON	2008/04/28 16:34

L7	4795	(CMP or chemical mechanical polishing) and (silica or sio2 or "sio.sub.2" or silicon dioxide or silicon oxide) and (alkali or KCL or "K.sub.2" "SO. sub.4" or "KNO. sub.3" or NaCl or "Na.sub.2" "so. sub.4" or "nano. sub.3" or "nh. sub.4" cl or "nh. sub.4" "no.sub.3" or potassium chloride or sodium chloride or ammonium chloride or ammonium nitrate or potassium nitrate) and (base or basic or alkali)	US-PGPUB; USPAT	ADJ	ON	2008/04/28 17:09
L8	1321	(CMP or chemical mechanical polishing) and (silica or sio2 or "sio.sub.2" or silicon dioxide or silicon oxide) and (alkali or KCL or "K.sub.2" "SO. sub.4" or "KNO. sub.3" or NaCl or "Na.sub.2" "so. sub.4" or "nano. sub.3" or "nh. sub.4" cl or "nh. sub.4" "no.sub.3" or potassium chloride or sodium chloride or ammonium chloride or ammonium nitrate or potassium nitrate) and (base	US-PGPUB; USPAT	ADJ	ON	2008/04/28 17:11

		or basic or alkali) and water and wafer and pad				
L9	320	(CMP or chemical mechanical polishing) and (silica or sio2 or "sio.sub.2" or silicon dioxide or silicon oxide) and (alkali or KCL or "K.sub.2" "SO. sub.4" or "KNO. sub.3" or NaCl or "Na.sub.2" "so. sub.4" or "nano. sub.3" or "nh. sub.4" cl or "nh. sub.4" "no.sub.3" or potassium chloride or sodium chloride or ammonium chloride or ammonium nitrate or potassium nitrate) and (base or basic or alkali) and water and wafer and pad and (aggregate or accumulate or cluster or flocculat \$3 or clump)	US-PGPUB; USPAT	ADJ	ON	2008/04/28 17:13

4/28/2008 5:16:31 PM